

Wafer-scale Hierarchical Nanopillar Arrays Based on Au Masks and Reactive Ion Etching for Effective 3D SERS Substrate

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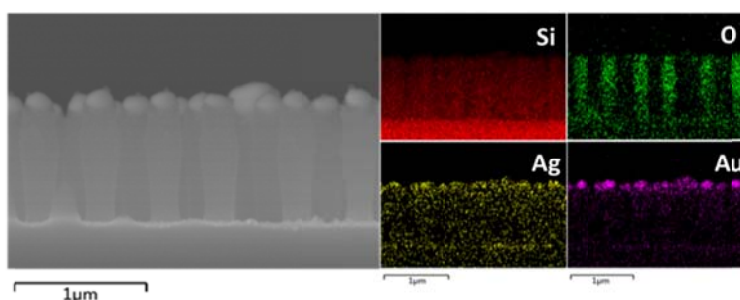


Figure S1. Elemental mapping images of the SiO₂ nanopillar arrays decorated with Ag NPs.

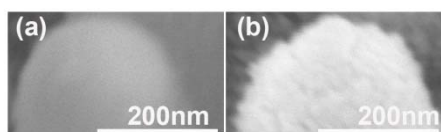


Figure S2. Comparison of surfaces for Au-Ag alloy NP on the as-prepared periodic hierarchical SiO₂ nanopillar array before (a) and after (b) depositing Au film.

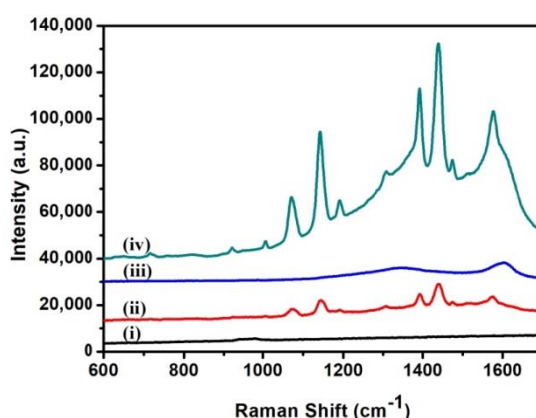


Figure S3. Comparison of average Raman spectra for the 10⁻⁴ M 4-ATP on the SiO₂ nanopillars array (i), SiO₂ nanopillars with the Ag film (ii), SiO₂ nanopillar arrays decorated with Ag NPs (iii) and SiO₂ nanopillar arrays decorated with Ag NPs after depositing Au film (iv).